



Single-Event Effects in Silicon and Silicon Carbide Power Devices

**Jean-Marie Lauenstein, Megan C. Casey, and
Kenneth A. LaBel**

Code 561, NASA Goddard Space Flight Center

**Alyson D. Topper, Edward P. Wilcox,
Hak Kim, and Anthony M. Phan
ASRC Space & Defense**



List of Acronyms

BJT – Bipolar Junction Transistor

BV_{dss} – Drain-to-Source Breakdown Voltage

ETW – Electronic Technology Workshop

FY – Fiscal Year

GRC – Glenn Research Center

GSFC – Goddard Space Flight Center

HEMT – High Electron-Mobility Transistor

I_D – Drain current

I_G – Gate current

JEDEC – (not an acronym)

JESD – JEDEC Standard

JFET – Junction Field-Effect Transistor

JJAP – Japanese Journal of Applied Physics

JPL – Jet Propulsion Laboratory

LBNL – Lawrence Berkeley National Laboratory 88-Inch cyclotron

LET – Linear Energy Transfer

MOSFET – Metal Oxide Semiconductor Field Effect Transistor

NEPP – NASA Electronic Parts and Packaging program

PIGS – Post-Irradiation Gate Stress

RF – Radio Frequency

SEB – Single-Event Burnout

SEE – Single-Event Effect

SEFI – Single-Event Functional Interrupt

SEGR – Single-Event Gate Rupture

SEP – Solar Electric Propulsion

SET – Single-Event Transient

SOA – State-Of-the-Art

TID – Total Ionizing Dose

VDMOS – vertical, planar gate double-diffused power MOSFET

V_{DS} – Drain-source voltage

V_{GS} – Gate-source voltage

V_R – Reverse-bias Voltage

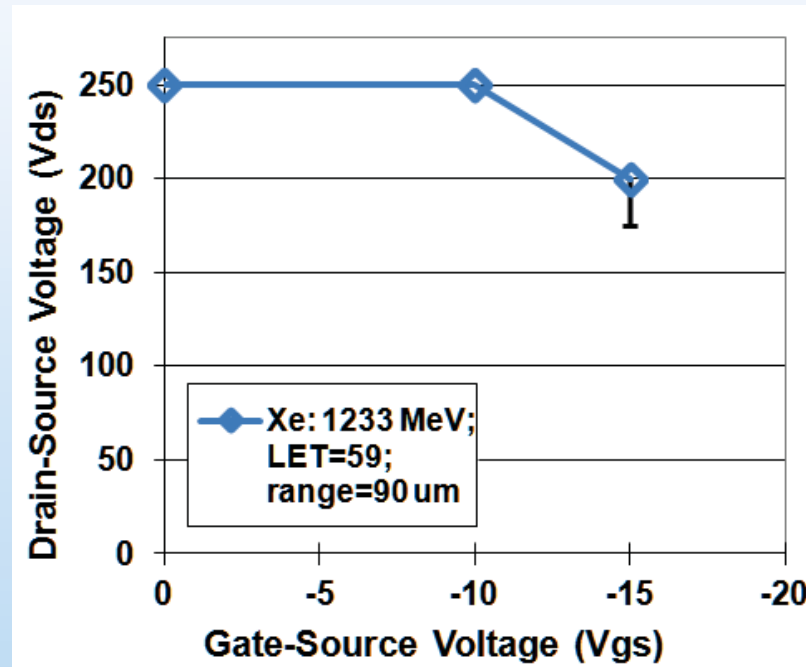


Goals

- **Assess SiC power devices for space applications**
 - Develop relationships with SiC device suppliers
 - Investigate SEE susceptibility of currently available products
 - Understand SEE mechanisms to enable radiation hardening
- **Participate in test method revisions:**
 - Lead JEDEC JESD57 revision: “Test Procedure for the Measurements of Single-Event Effects in Semiconductor Devices from Heavy Ion Irradiation” – current version is from 1996
- **Evaluate alternative silicon power MOSFETs for space applications**
 - Winding down focus on Si VDMOS: We’ve gone from 1 to 6 manufacturers offering independently verified SEE radiation-hardened discrete silicon power MOSFETs!
 - Thank you to all manufacturers who partnered with us over the years to provide this critical product to the aerospace community
 - *We are always interested in SOA high-performance Si MOSFETs..*

Si Power MOSFETs

- **FUJI advanced 2nd generation radiation-hardened VDMOS:**
 - Developed to withstand PIGS test
 - Hardness of 250 VDMOS evaluated at LBNL – failures only at -15 Vgs
 - 500 V device in development



Single-event effect response curve of FUJI engineering samples of new 250 VDMOS

- **NEPP (JPL) invited to observe Microsemi 2nd generation i2MOSTM SEE testing this summer**

To be published on nepp.nasa.gov previously presented by Jean-Marie Lauenstein at the NASA Electronic Parts and Packaging (NEPP) Electronics Technology Workshop (ETW), Greenbelt, MD, June 17-19, 2014.

JEDEC Standard No. 57 (JESD57)

Revision Efforts



JESD57: “Test Procedures for the Measurement of Single-Event Effects in Semiconductor Devices from Heavy Ion Irradiation”

- **FY13 efforts: update SEGR test method within JESD57**
 - Current understanding of ion species and energy effects
 - Guidance for beam selection based on species
 - Scope expanded:
 - Discrete MOSFETs of various topologies
 - Microcircuits
- **FY14 efforts include complete JESD57 update**
 - Document reorganization
 - Addition of SEB, SET
 - Expansion of SEFI understanding
 - and more



JESD57 Content Revision

- **Key content updates:**
 - **Basic effects expanded to better address:**
 - SEB, SEFIs, SEGR, SETs
 - Effects not well understood to be addressed as “notes”:
 - SiC and Si Schottky burnout-like failures
 - RF SEE challenges, including on-state catastrophic failures in GaN HEMTs
 - **Definitions updated to current JESD88**
 - Some definitions are still out-of-date – need to be expanded to reflect current understanding of effects
 - SEFI, SEU
 - **DUT preparation expanded**
 - Die thinning
 - High-voltage die arcing after decapsulation
 - **Dosimetry practices updated**
 - **Document reorganized for improved readability**

SiC Power Devices Evaluated to Date



Part Type	Manufacturer	Part Number	Date Tested
Schottky (1200 V)	Cree	C4D40120D*	Spr 2013
	GeneSiC	GB20SLT12*	Sum 2013
Schottky (650 V)	Infineon	IDW40G65C5*	Sum 2013
MOSFET (1200 V)	Cree	Gen 2.0*	Fall 2013
		Gen 1.5 (prototype)*	Fall 2013
		Gen 1.0	Fall 2012
	Cisoid	CHT-PLA8543C*	Sum/Fall 2013
NPN BJT (1200 V)	TranSiC (now Fairchild)	BT1206AA-P1	Sum 2012
JFET, normally off (1200 V)	SemiSouth	SJEP120R100	Sum 2012
JFET, normally off (1700 V)	SemiSouth	SJEP170R550	Fall 2012

*** Evaluated under the NASA SEP Program with support from NEPP**

To be published on nepp.nasa.gov previously presented by Jean-Marie Lauenstein at the NASA Electronic Parts and Packaging (NEPP) Electronics Technology Workshop (ETW), Greenbelt, MD, June 17-19, 2014.

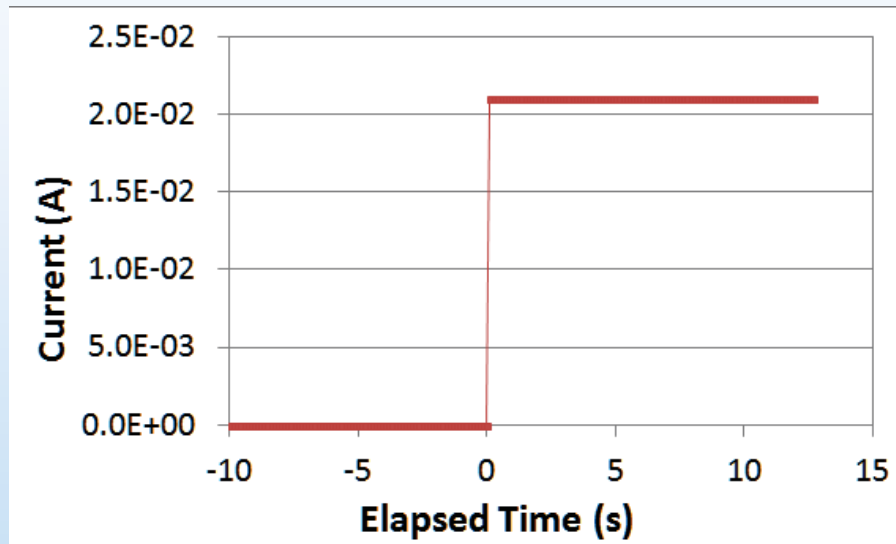


SiC Schottky Diodes

- **Two modes of SEE effects, both reported previously in the literature**
 - Degradation
 - Catastrophic failure
- **Degradation (increasing reverse-bias leakage current) prevents identification of onset bias for single-event catastrophic failure**
- **As previously reported, catastrophic failure can occur under proton irradiation**
- **Failure location within active region (as opposed to field termination region)**
 - To be verified via failure analysis

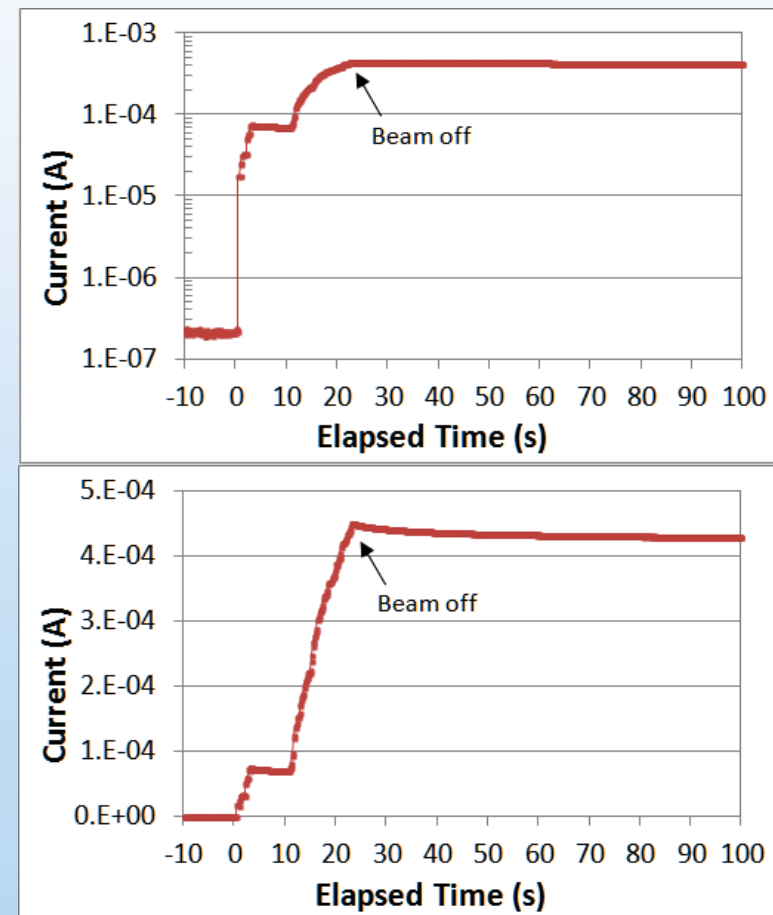
GB20SLT12 Current Signatures

Ag: $V_R = 500$ V
 avg. flux = 24 /cm²/s:
 Immediate catastrophic failure



1110 MeV Ag ions:
LET = 66 MeV-cm²/mg
Range = 49 μ m

Ag: $V_R = 350$ V
 avg. flux = 589 /cm²/s:
 Degradation

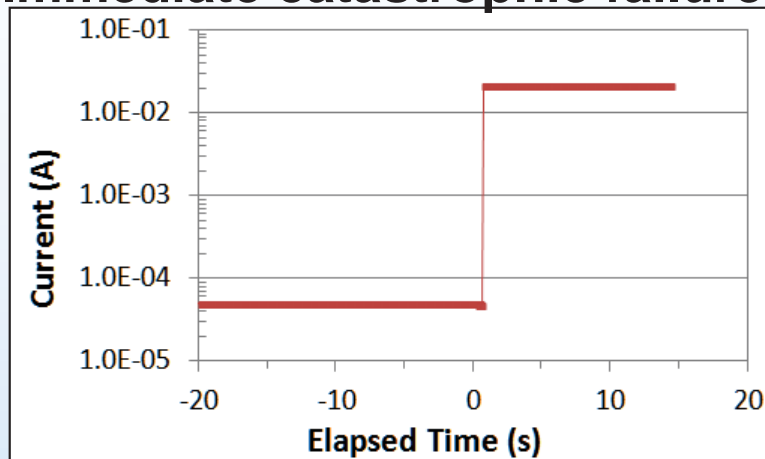


C4D40120D Current Signatures

Ag: $V_R = 650$ V

avg. flux = 1088 /cm²/s:

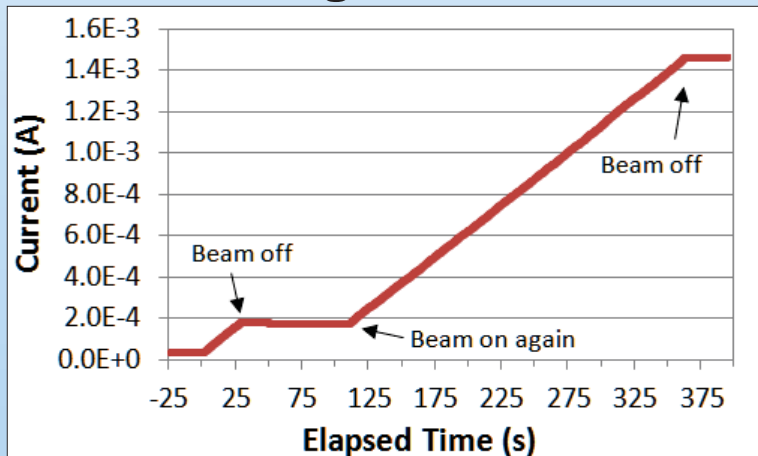
Immediate catastrophic failure



Ag: $V_R = 300$ V

ave flux = 1088 /cm²/s:

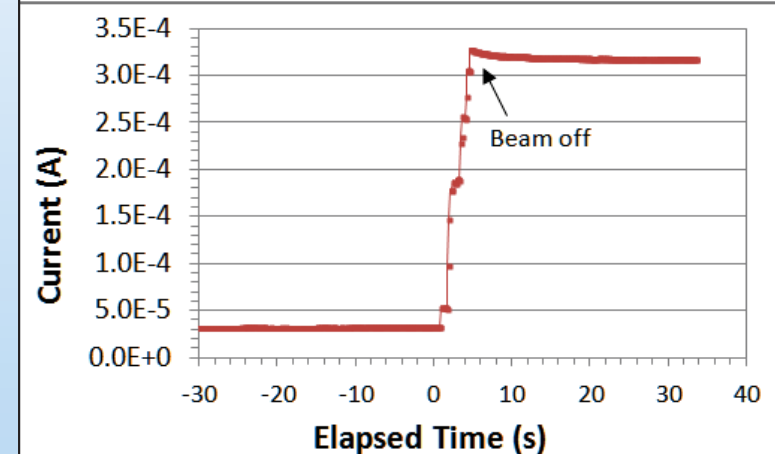
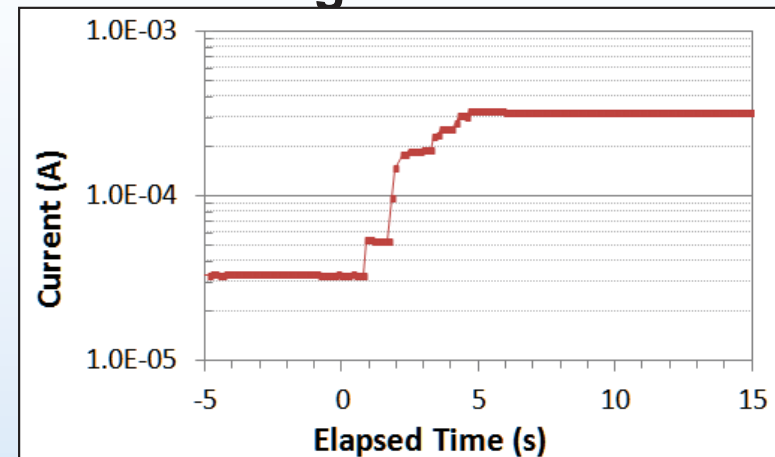
Degradation



Ag: $V_R = 450$ V

avg. flux = 63 /cm²/s:

Degradation



1110 MeV Ag ions:

$LET = 66$ MeV-cm²/mg; Range = 49 μ m

SiC Schottky Diode Damage Signatures



- **Degradation of reverse current:**
 - Influenced by ion/energy
 - Have not looked at multiple energies for single ion species to isolate energy effects
 - Influenced by reverse bias voltage
 - Does not recover after irradiation
 - Failure analyses to be done to see extent of damage



SiC Power MOSFETs

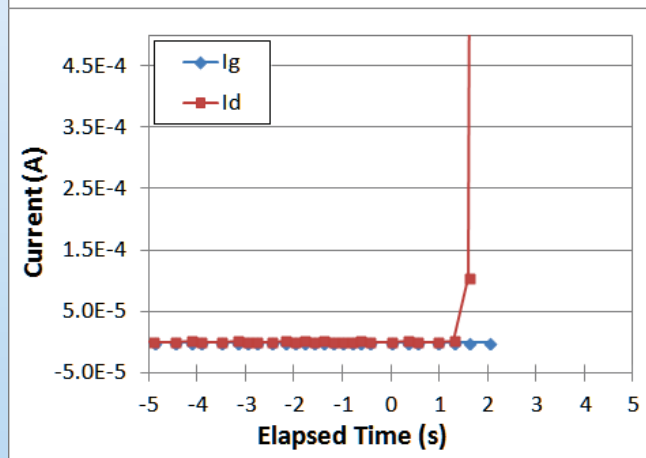
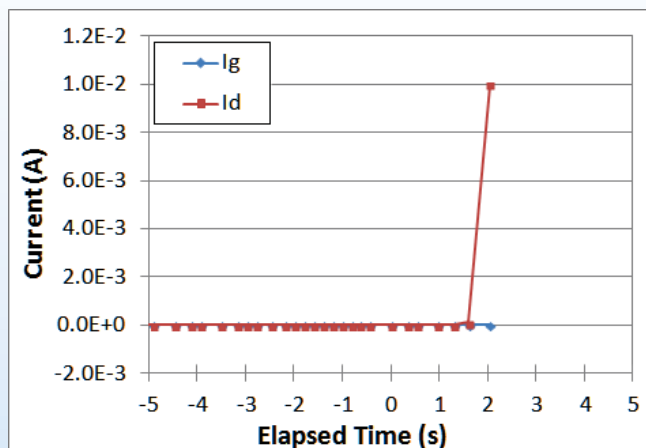
- **Two modes of SEE effects as with Schottkys**
 - Degradation
 - Catastrophic failure
- **Unclear what the primary failure mode is**
 - Both gate and drain current increases
 - Substantially thinner gate oxide in Cree generation 2.0 does not result in increased SEGR susceptibility
 - Cree Gen 1.5 shows predominately SEGR signatures
 - Cree Gen 2 shows predominately burnout-like damage
- **Susceptibility falls off with angle of incidence**
 - assessed only in Cree Gen 1 parts
- **Titus-Wheatley critical V_{GS} at 0 V_{DS} holds (unchanged) for Cree MOSFETs (established on gen 1.0)**

$$V_{gs(crit)} = \frac{10^7 \times t_{ox}}{1 + \frac{Z}{44}}$$

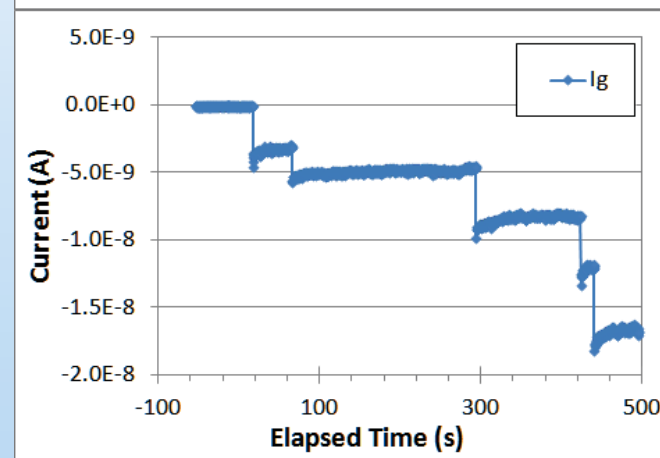
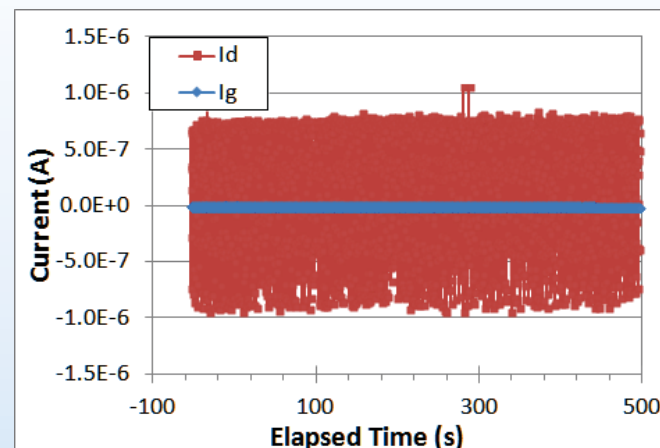
Cree Gen. 2.0 Signatures: Catastrophic Failure; Gate Degradation



Xe: 650 V_{DS}; 0 V_{GS}
avg. flux = 17 /cm²/s



Xe: 300 V_{DS}; 0 V_{GS}
avg. flux = 13.5 /cm²/s

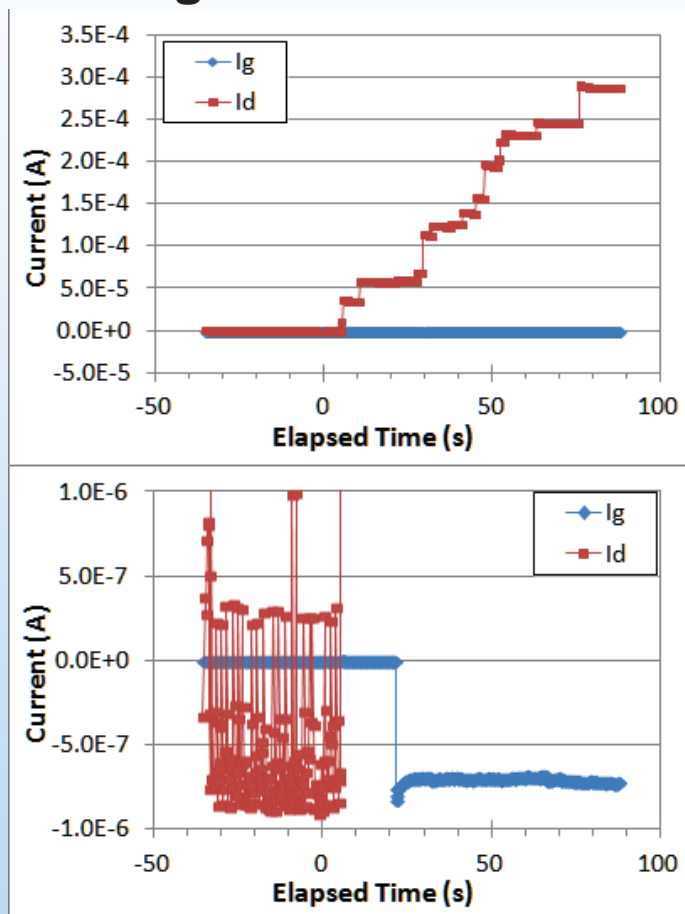


996 MeV Xe ions:

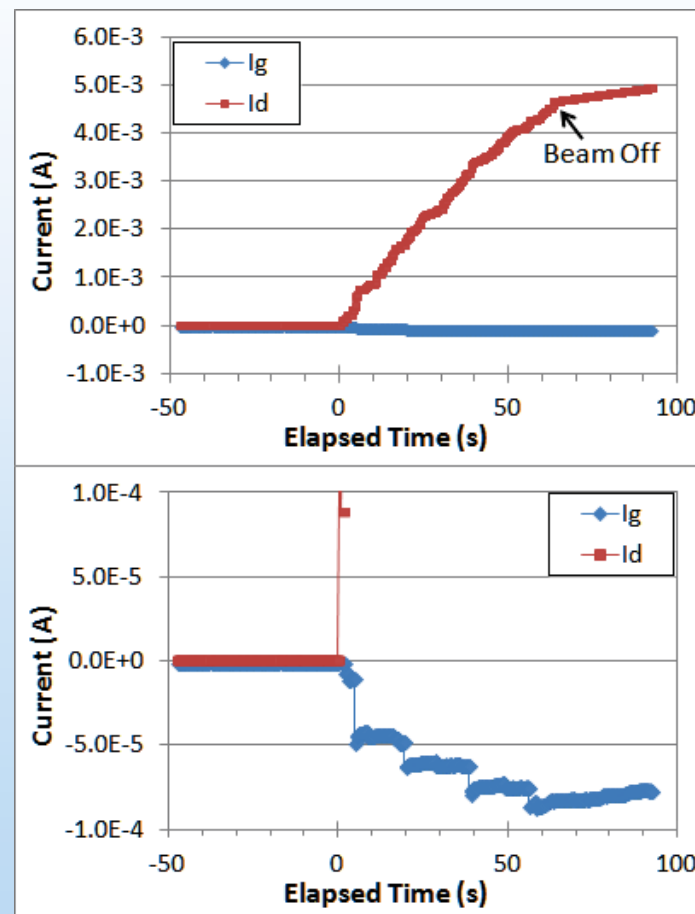
LET = 65 MeV-cm²/mg, Range = 49 μm

Cree Gen. 2.0 Signatures: Drain-Source Damage

Xe: 500 V_{DS}
avg. flux = 6 /cm²/s



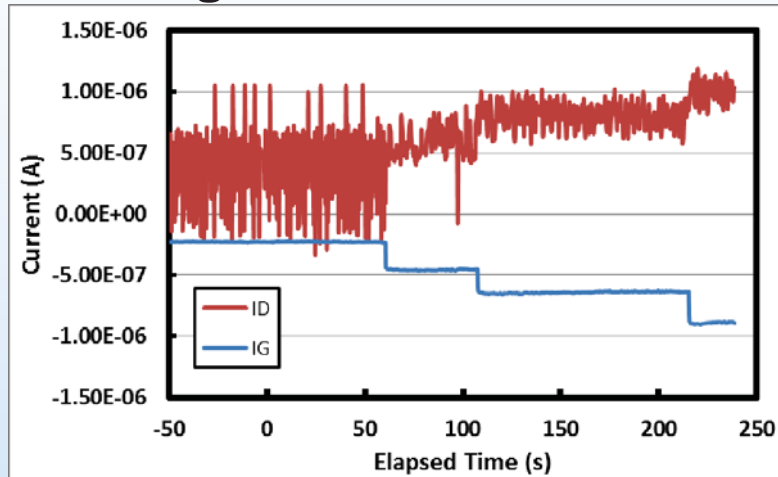
Xe: 500 V_{DS}
avg. flux = 162 /cm²/s



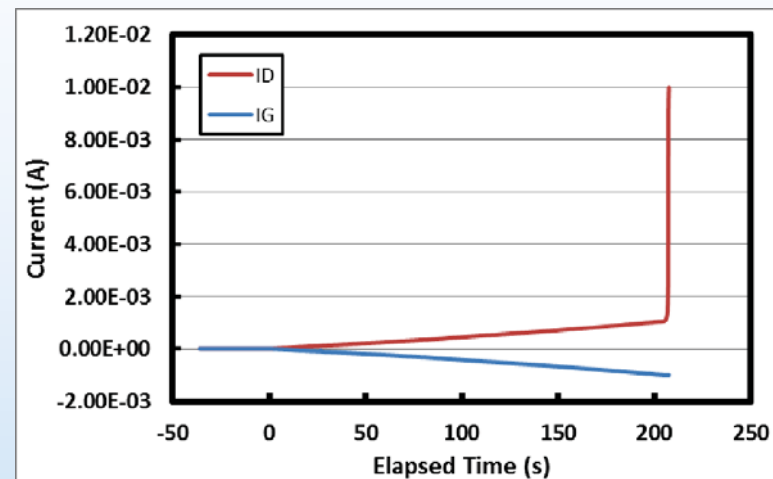
996 MeV Xe ions:
LET = 65 MeV-cm²/mg, Range = 49 μm

Cree Gen. 1.5 Signatures: Gate-Drain damage

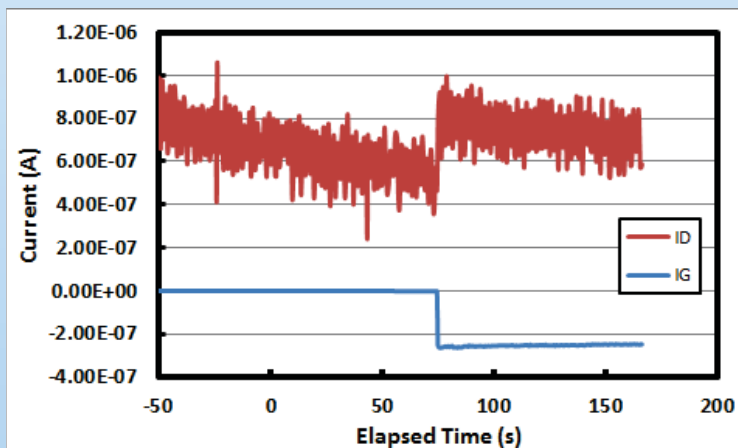
Xe: 182 V_{DS}
avg. flux = 45 /cm²/s



Xe: 400 V_{DS}
avg. flux = 484 /cm²/s



Xe: 182 V_{DS}
ave flux = 68 /cm²/s

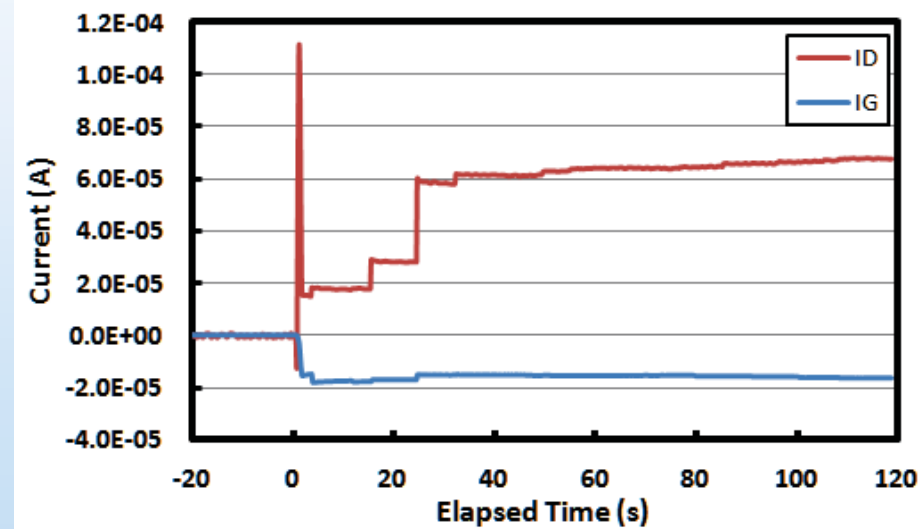
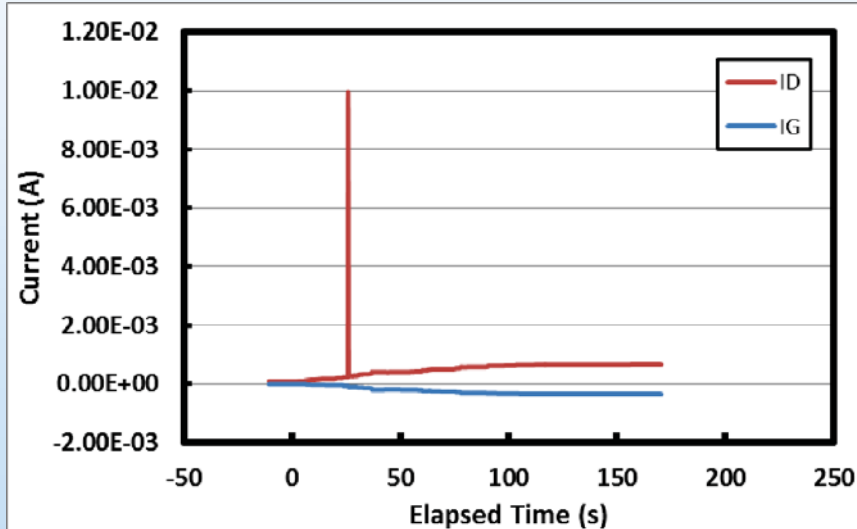


After run on left. BV_{dss} = 912 V (BV_{dss} defined at I_D = 100 μA). PIGS = 40 μA at 18 V_{GS}, 0 V_{DS}.

Cree Gen. 1.5 Details: “Protective Mode” Test

Xe: 500 V_{DS}
avg. flux = 5 /cm²/s
Unprotected test

Xe: 500 V_{DS}
avg. flux = 5 /cm²/s
1 MΩ on drain node



With protective resistor:

- $\Delta I_D > \Delta I_G$
- I_G shows some temporary recovery
- Failure mode is not pure SEGR



Power MOSFETs (cont'd)

- **Revisit protective mode:**
 - Apply lower V_{DS} conditions
 - Examine Cree Gen 2 where drain current effects predominate
- **Revisit Cree Gen 1 test data to assess predominate failure signature**
- **STMicro SiC power MOSFETs to be evaluated June 29th**
 - Designer will be present
- **Negotiating with GeneSiC to obtain samples of their SiC Junction Transistor**



Conclusions and Path Forward

- **SiC devices show high TID tolerance, but low SEE tolerance**
 - Degradation occurs well below rated bias voltage
 - Increased leakage currents with ion fluence are a function of LET and bias voltage on the part
- **Identification of a safe operating condition is extremely difficult**
 - Degradation interferes with adequate sampling of the die with ions – many samples would be required
 - Degradation may impact part reliability
- **Signatures are similar across manufacturers and part types:**
 - Mechanism is more fundamental than geometry or process quality
 - Recent research (Shoji, *JJAP*, 2014) suggests impact ionization at the epi/substrate interface due to the space-charge induced increase in the electric field results in thermal damage (SEB)
 - **Vulnerability tied to much higher heat generation density in SiC vs. Si**